



AF 22

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Paul B. Mirkarimi et al.

Docket No. : CIL-10972

Serial No. : 10/086,614

Art Unit : 1762

Filed : March 1, 2002

Examiner : A. Bashore

For : Ion-Assisted Deposition Techniques for
the Planarization of Topological Defects

NOTICE OF APPEAL FROM THE EXAMINER TO THE BOARD OF PATENT
APPEALS AND INTERFERENCES

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:


Applicant hereby appeals to the Board of Patent Appeals and Interferences
from the decision of the examiner, dated September 20, 2006, rejecting claims: 1-20.

The fee for this Notice is (37 CFR 1.17(b)) \$500. The Commissioner is hereby
authorized to charge any fees that may be required, or credit any overpayment to
Deposit Account No. 501913. A duplicate copy of this sheet is enclosed.

If any impediments remain, please contact the undersigned at 808-875-0012.

02/27/2007 MWOLDGE1 00000011 501913 10086614
01 FC:1401 500.00 DA

Respectfully submitted,


John P. Wooldridge
Attorney for Applicant
Registration No. 38,725

Dated: February 20, 2007